Kinetic Resolution of (\pm)-Cyclohex-1-enylsilanols by the Sharpless Asymmetric Epoxidation

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Unprecedented kinetic resolution of (\pm) -cyclohex-1-enylsilanols **1** by the Sharpless asymmetric epoxidation has been accomplished, the rate difference between enantiomers, $k_{\rm rel}$, being >11 to give enantiomerically pure cyclohex-1-enylcyclohexylmethylsilanol **1b** in a particular case.

We report here the first example of kinetic resolution *via* the Sharpless epoxidation¹ of racemic cyclohex-1-enylsilanols 1 [eqn. (1)]. Although it is known that one should be wary of attempting to asymmetrically epoxidize or kinetically resolve allylic alcohols of high steric demands,² there has been a report³ which involves an efficient asymmetric epoxidation of dimethylstyrylsilanol, a sila-analogue of *tertiary* allylic alcohol, under the standard Sharpless conditions.^{1b} However, our attempted epoxidation of racemic methylphenylstyrylsilanol was found to exhibit neither acceptable diastereoselection in the epoxides nor detectable kinetic resolution in the substrate, but rather resulted in forming siloxane predominantly.

The desired cyclohex-1-enylmethylphenylsilanol $1a^{\dagger}$ was prepared by a sequential introduction of phenylmagnesium bromide and cyclohex-1-enyllithium to MeSiCl₃ to give c-C₆H₉MePhSiCl which in turn was hydrolysed using a buffer solution (KH₂PO₄-NaOH, pH 7.0). Also, cyclohex-1-enylcyclohexylmethylsilanol $1b^{\dagger}$ was obtained by way of the Pt-catalysed hydrosilylation of cyclohexene with HSiMeCl₂ to give an intermediate dichlorosilane, c-C₆H₁₁MeSiCl₂.

The stoichiometric Sharpless epoxidation of **1a** (1 mmol) using Ti(OPrⁱ)₄-(+)-diisopropyl tartrate (DIPT)-BuⁱO₂H (TBHP: 2.9 mol dm⁻³ isooctane solution) in a ratio 1.0:1.2:0.6 in dry CH₂Cl₂ (10 ml) at -20 °C for 2 days proceeded steadily to form a diastereoisomer mixture of 1,2-epoxycyclohexylmethylphenylsilanol (**2a** and **3a**)† in a ratio 75:25 in 43% combined yield (at 57% conversion) along with a recovery of **1a** in 32% isolated yield. The enantiomeric excess (e.e.) of each component was determined by ¹H NMR using a chiral

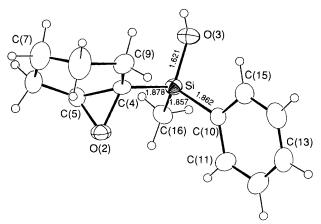


Fig. 1 Molecular structure of 2a. Selected intramolecular distances (Å) are given.

shift reagent, Eu(hfc)₃‡ to be 8% e.e. (1a), 8% e.e. (2a) and 15% e.e. (3a), respectively. Thus, the calculated rate difference, $k_{\rm rel}$, was 1.2. [By definition, $k_{\rm rel} = k_{\rm fast}/k_{\rm slow} = \ln(1-\text{conv})(1-\text{e.e.})/\ln(1-\text{conv})(1+\text{e.e.})$]. In addition, it is noteworthy that, without any tartrate ligand, the epoxidation of 1a proceeded very rapidly in the presence of 1 equiv. of Ti(OPri)₄ and TBHP, respectively, reaching almost completion in 3 h and that the diastereoselection for 2a and 3a was unchanged (75:25).

That the major epoxidation product is *erythro* was confirmed by an X-ray crystallography§ (see Fig. 1) of pure 2a which was obtained by rapid epoxidation of 1a. We have also prepared, from natural cholesterol and racemic c- C_6H_9 MePhSiCl, 3-silyl-protected cholesterol 4 which forms colourless crystals. The diastereoisomeric mixture of 4 was resolved by recrystallization (from hexane–acetonitrile) to form single crystals 4a, † an X-ray structure¶ of which is shown in Fig. 2, indicating an absolute configuration at the silicon atom S. Cleavage of 4a with powdered KOH in hot xylene followed by hydrolysis (retention of configuration at Si)⁴ gave (S)sicyclohex-1-enylmethylphenylsilanol [(S)si-1a], which was fortuitously identical to that recovered from the present kinetic

 \ddagger Abbreviations used: Eu(hfc)_3 = tris[3-heptafluoropropylhydroxymethylene-(+)-camphorato]europium(III). Eu(fod)_3 = tris-(6, 6, 7, 7, 8, 8, 8-heptafluoro-2, 2-dimethyl-3, 5-octanedionato)europium(III). Eu(dppm)_3 = (+)-tris[di(perfluoro-2-propoxypropionyl)-methanato]europium(III).

§ Crystal data for 2a: $C_{13}H_{18}O_2Si$, M=234.36, monoclinic, space group C2/c (No. 15), a=29.459(11), b=5.7431(8), c=16.993(4) Å, $\beta=117.61(2)^\circ$, V=2548(1) Å³, Z=8, $D_c=1.194$ g cm⁻³, λ (Mo-Kα) = 0.71059 Å, μ (Mo-Kα) = 1.62 cm⁻¹. Final R value 0.086, $R_w=0.088$ for 2458 reflections with $F_o>3\sigma(F_o)$. Intensity data were collected at 25 °C on a Rigaku AFC-5 automated four-circle diffractometer with graphite-monochromated Mo-Kα radiation in the $2^\circ<2\theta<55^\circ$ range. Data processing was performed on a FACOM A-70 computer by using the R-CRYSTAN structure solving system obtained from the Rigaku Corp., Tokyo, Japan. The position of the Si atom was located by the direct method (SAPI 85). Subsequent difference Fourier synthesis revealed the positions of all the non-hydrogen atoms were refined anisotropically, and the positions of the hydrogen atoms were confirmed with B(H)=0.9 B (C or O).

¶ Crystal data for 4a: $C_{40}H_{62}OSi$, M=587.025, monoclinic, space group C2, a=44.870(2), b=6.065(2), c=13.920(2) Å, $\beta=102.269(7)^\circ$, V=3701(1) ų, Z=4, $D_c=1.053$ g cm⁻³, $\lambda(Cu\text{-}K\alpha)=1.54184$ Å, $\mu(Cu\text{-}K\alpha)=6.77$ cm⁻¹, Final R value 0.071, $R_w=0.087$ for 2058 relfection with $F_o>3.0\sigma$ (F_o). Diffraction measurement was made on a Rigaku AFC-5R four-circle diffractometer by using graphite-monochromated Cu-K α radiation in the 3° < 20 < 125°. Data processing was performed on a Micro VAX II computer by using the TEXSAN crystallographic software package (Molecular Structure Corp., 1985). The structure was solved by direct methods and refined by full-matrix least-squares. Hydrogen atoms were calculated geometrically except those attached to C(1) to C(12), C(39) and C(40) which have large thermal parameters. Non-hydrogen atoms were refined with fixed isotropic thermal parameters.

Atomic coordinates, bond lengths and angles, and thermal parameters for compounds 2a and 4a have been deposited at the Cambridge Crystallographic Data Centre. See Notice to Authors, Issue No. 1.

 $[\]dagger$ All new compounds prepared here gave satisfactory spectral and analytical data.

Fig. 2 ORTEP drawing of $(S)_{Si}$ -[(cholest-5-en-3 β -yl)oxy]cyclohex-1-enylmethylphenylsilane **4a**

resolution of (\pm) -1a (a sample with 20% e.e. obtained in another run). Thus, in consonance with the proposed transition state models for the asymmetric epoxidation of secondary allylic alcohols, ^{1c} we have identified both the moderate diastereoselectivity for 2a over 3a in the smooth epoxidation of a sila-analogue of tertiary allylic alcohol, 1a, to be *erythro* and the fast reacting enantiomer in the epoxidation using the natural tartrate-Ti(OPr¹)₄-TBHP to be $(R)_{Si}$ -1a, the efficiency of kinetic resolution being poor.

When 1b was used, we have observed a definite rate difference in epoxidation, $k_{rel} = 3.6$, which results in giving enantiomerically enriched 1b: To a mixture of (+)-DIPT (0.37 g, 1.6 mmol), **1b** (0.15 g, 0.66 mmol) and powdered molecular sieve 4A (300 mg) in dry CH_2Cl_2 (7 ml), cooled to $-20\,^{\circ}C$ under an argon atmosphere, was added $Ti(OEt)_4$ (0.27 ml, 1.3 mmol) and the mixture was stirred for 0.5 h. Then, TBHP (3.4 mol dm⁻³ in CH_2Cl_2 , 0.15 ml) was added and the whole mixture was stored at -20° C for 39 h. After the usual workup, a mixture (0.46 g) of 1b, 2b and 3b along with (+)-DIPT was obtained. An aliquot (5 mg) was analysed by ¹H NMR using Eu(fod)₃‡ (4.9 mg) to determine the conversion (64%) and the diastereoisomer ratio (2b:3b = 94:6). The remaining product mixture was separated by silica-gel column chromatography (eluent hexane-diethyl ether, 7:1) to give 1b (58 mg, 39% recovery) and a mixture of 2b and 3b† (95 mg, 60% yield) as white crystals. The e.e.s of 1b, 2b and 3b were determined using either Eu(dppm)₃‡ (20 mol%) or Eu(hfc)₃ (10 mol%), respectively, to be 62% 1b, 30% 2b and 52% **3b**; **1b**, $[\alpha]_D^{25} + 4.9$ (c 0.49, cyclohexane). Furthermore, it is noted that among two sets of enantiomeric methyl singlets of ¹H NMR signals for **2b** and **3b** in the presence of Eu(hfc)₃, both the most-shifted signal 2b and the least-shifted one 3b

exhibit the respective major enantiomer, most probably corresponding to the same configuration R at the silicon atom, and that this is the case for 2a and 3a described above. By substituting (-)-dicyclododecyl tartrate (DCDT: an unnatural tartrate) for (+)-DIPT and with added molecular sieve 4A under otherwise equal conditions, we have observed even higher rate difference $k_{\rm rel} > 11$ at 71% conversion in the epoxidation, which gives rise to $(R)_{\rm Si}$ -1b with >99% e.e., diastereoisomer ratio being practically unchanged (2b:3b=95:5).

In conclusion, although it is still unclear whether the reaction system for the epoxidation of the sila-analogue of *tertiary* allylic alcohols 1 is too congested around the chirally modified Ti atom(s) to exhibit effective rate discrimination between the enantiomers of 1, we have achieved $k_{\rm rel} > 11$ using 1b under proper Sharpless conditions.

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